EAST Search History

SOR 101	605,	618
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Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	328	(gate and silicide and anisotropic and etch\$3 and mask\$3).CLM.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/25 15:22
L2	39	(gate and silicide and anisotropic and etch\$3 and mask\$3 and polysilicon and (cap or capping)). CLM.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/25 15:22

Sor 10/605,618

Refine Search

Search Results -

Terms	
(polycide adj gate) and (anisotropic\$5 near2 etch\$4) and (cap or capping) and mask\$4 and (etch\$4 same (indent\$5 or sidewall\$1))	108

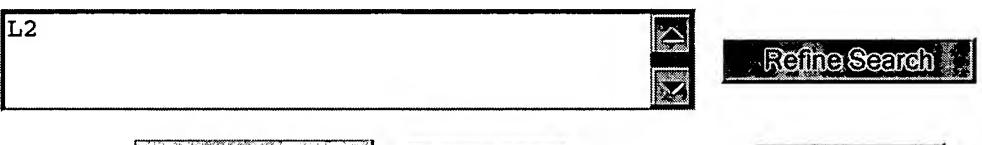
US Pre-Grant Publication Full-Text Database

US Patents Full-Text Database US OCR Full-Text Database

Database:

EPO Abstracts Database JPO Abstracts Database **Derwent World Patents Index IBM Technical Disclosure Bulletins**

Search:









Search History

DATE: Thursday, May 25, 2006 Printable Copy Create Case

Set Name side by side	Query	<u>Hit</u> Count	Set Name result set
$DB = I$ $\underline{L2}$	PGPB, USPT, USOC, EPAB, JPAB, DWPI, TDBD; PLUR=YES; OP=ADJ (polycide adj gate) and (anisotropic\$5 near2 etch\$4) and (cap or capping) and mask\$4 and (etch\$4 same (indent\$5 or sidewall\$1))	108	<u>L2</u>
DB=0	USPT; PLUR=YES; OP=ADJ		
<u>L1</u>	(polycide adj gate) and (anisotropic\$5 near2 etch\$4) and (cap or capping) and mask\$4 and (etch\$4 same (indent\$5 or sidewall\$1))	89	<u>L1</u>

END OF SEARCH HISTORY